

Supporting Information

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SI Text

S1) Derivation of the Wind-Chime Model

Each pulse generates an angular momentum on each MoS₂ flake that makes them rotate unless they develop an axis parallel to the laser beam polarization. This is also associated with rotation of a small portion of the liquid nearby the flake surface. Then, the viscous force at the flake edge reduces the angular velocity exponentially until it becomes static. When the next pulse arrives, the same process repeats, where the integrated result is the macroscopic angular motion of the flake (i.e., the formation of the wind chime).

Taking $E(z, t) = E_0 e^{-((ct-z)^2/c^2\tau^2)} \sin(kz - \omega_0 t)$, where τ is pulse width, we have $I = \varepsilon E^2 c = (c/2T) \varepsilon_0 E_0^2 \tau \sqrt{\pi/2}$, where T is the period of pulse repetition and we have assumed $2\pi/\omega_0 \ll \tau$. The electrical polarization in the flake domain is $\mathbf{P} = (\varepsilon_r - 1) \varepsilon_0 \mathbf{E} \cos \theta$. In molybdenum disulfide the electrical field is E/ε_r . Thus, assuming a circular disk shape for the flake domains, the rotation torque generated by the laser pulse $\mathcal{M} = \int |\mathbf{P} \times \mathbf{E}| dV$ has a magnitude of

$$\mathcal{M} = \frac{1}{4} \sin 2\theta \frac{(\varepsilon_r - 1)}{\varepsilon_r} \varepsilon_0 E_0^2 \pi R^2 h e^{-(2(ct-z)^2/c^2\tau^2)}, \quad [\text{S1}]$$

where R is the disk radius and h is the disk thickness. Thus, when a pulse traverses the disk, the initial angular velocity acquired is

$$\Omega_0 = \frac{\int \mathcal{M} dt}{J_{\text{MoS}_2} + J_{\text{Solution}}} = \frac{\frac{1}{4} \sin 2\theta \frac{(\varepsilon_r - 1)}{\varepsilon_r} \varepsilon_0 E_0^2 \pi R^2 h \sqrt{(\pi/2)\tau}}{J_{\text{MoS}_2} + J_{\text{Solution}}}. \quad [\text{S2}]$$

Considering Newton's fluid with constant viscosity coefficient η and linear velocity v at the interface between the rotating and nonrotating parts, the rotation torque \mathcal{V} due to the viscous force is

$$\mathcal{V} = \eta \int_0^\pi \frac{dv}{dr} (R \sin \varphi) (\xi \cdot 2\pi R \sin \varphi) (R d\varphi) = \pi \eta \Omega \xi R^3, \quad [\text{S3}]$$

where Ω is the rotation velocity and ξ is the portion of the globe that is rotating together with the disk. Here ξ assumes a value between 0 and 1 and we estimate it to be closer to 0, because for each pulse the rotation has to be slow and not much fluid will sense the rotation before it reaches the static state. Hence in the relaxation process induced by the viscous force we obtain $\Omega = \Omega_0 e^{-(\pi \eta \xi R^3 / (J_{\text{MoS}_2} + J_{\text{Solution}})) t}$. With Eq. S2, the rotation angle accumulated due to each single light pulse is thus

$$\delta\theta = \int_0^T \Omega dt \approx \int_0^\infty \Omega_0 e^{-(\pi \eta \xi R^3 / (J_{\text{MoS}_2} + J_{\text{Solution}})) t} dt = \frac{(\varepsilon_r - 1)}{\varepsilon_r} \frac{2T I h}{4\eta \xi R c} \sin 2\theta. \quad [\text{S4}]$$

The time for the pattern formation is

$$\sum_{i=1}^N \delta\theta_i = \frac{(\varepsilon_r - 1)}{\varepsilon_r} \frac{2T I h}{4\eta \xi R c} \cdot N \cdot \overline{\sin 2\theta_i}, \quad [\text{S5}]$$

where N is the number of laser pulses. Assume that the pattern formation time is approximately that needed for a flake at $3\pi/8$ to

rotate to $\pi/8$. Thus, we have $\overline{\sin 2\theta_i} \sim 0.86$ and $\sum_{i=1}^N \Delta\theta_i = \pi/4$. Therefore, the time needed for the pattern formation is

$$T = N \cdot T = \frac{\varepsilon_r \pi \eta \xi R c}{1.72(\varepsilon_r - 1) I h} = 0.3 \text{ s}, \quad [\text{S6}]$$

where we have used the values $\varepsilon_r = 3.33$ for MoS₂, $\eta = 3.2 \times 10^{-4}$ Pa·s for acetone, $R \sim 1 \mu\text{m}$, $h \sim 10 \text{ nm}$, $I = 250 \text{ W/cm}^2$, and $\xi \sim 0.03$ in our experiment. As a result, T does not depend on the laser repetition rate. In the extreme condition when the rate is approaching infinity, the above derivation approximately accounts for the case of a continuous wave laser beam excitation. So we have actually considered situations of both pulsed and cw laser beam excitations and the results are identical. This has been verified in our experiment. Note that apparently T is inversely proportional to the laser intensity. However, the value of ξ is somehow positively correlated to the intensity at a certain range of I . So the actual time T is not tightly dependent on the laser intensity either, which has also been confirmed in our experiment.

S2) Comparison of $\chi^{(3)}$ with Calculated Absorption Along z

From Fig. S1 it can be seen that our experimental results do not compare well with the theoretical absorption along z . At below 2 eV, the measured values are a few times higher than that of the theoretical calculation.

S3) Ring Number of the 532-nm Pattern as a Function of the Total Laser Intensity

In the main text we discussed the ring number of the 473-nm pattern. Here we show the other aspect of the same data (Fig. S4) by illustrating the ring number of the 532-nm pattern (Fig. S2).

S4) Relation Between the Fringe Thickness and the Flake Concentration

As shown in Fig. S3A (*Upper* panel is adopted from ref. 22 and *Lower* panel is adopted from ref. 14), the fringes are interfering results of the output beams having an identical wavevector. The width of the ring peak is determined by, for a given angle change in the wavevector, how much phase change is occurring ($k_\perp(r) = d\Delta\psi(r)/dr$). The larger $\chi^{(3)}$ is (or equivalently n_2), the more phase change, and hence the narrower the fringe. It is worth noting that both the bright and dark fringes change simultaneously. If more MoS₂ flakes are under illumination, the width becomes narrower due to enhanced $\chi^{(3)} = \chi_{\text{total}}^{(3)}$.

In Fig. S3B we show the results from two different samples. Fig. S3B, *Left* corresponds to a sample that has 85% MoS₂ concentration of that of Fig. S3B, *Right*; thus there are 85% MoS₂ flakes illuminated. All other factors of the experiment, including the screen and camera positions, are identical. Thus, $\chi_{\text{left}}^{(3)} = (M_{\text{left}}/M_{\text{right}})^2 \chi_{\text{right}}^{(3)}$, number of rings $N_{\text{left}} = (M_{\text{left}}/M_{\text{right}})^2 N_{\text{right}}$, and ring diameter $D_{\text{left}} = (M_{\text{left}}/M_{\text{right}})^2 D_{\text{right}}$, where M is the effective number of MoS₂ layers [note that in *Methods* we have $\chi^{(3)} = M^2 \chi_{\text{onelayer}}^{(3)}$]. In Fig. S3B, the ring diameter is enlarged by $(M_{\text{right}}/M_{\text{left}})^2 = (1/0.85)^2 = 1.4 \times$ and the number of rings is also enlarged by 1.4×. Therefore, the absolute ring thickness is unchanged (parallel white straight lines in Fig. S3B). However, the relative fringe thickness is narrowed: Because the number of rings is enlarged by 1.4×, the relative fringe thickness (absolute thickness divided by the ring diameter D) is narrowed by 1.4×, too. Conversely, if one takes the j th ring counted from the ring center, both its absolute and relative thicknesses are narrowed.

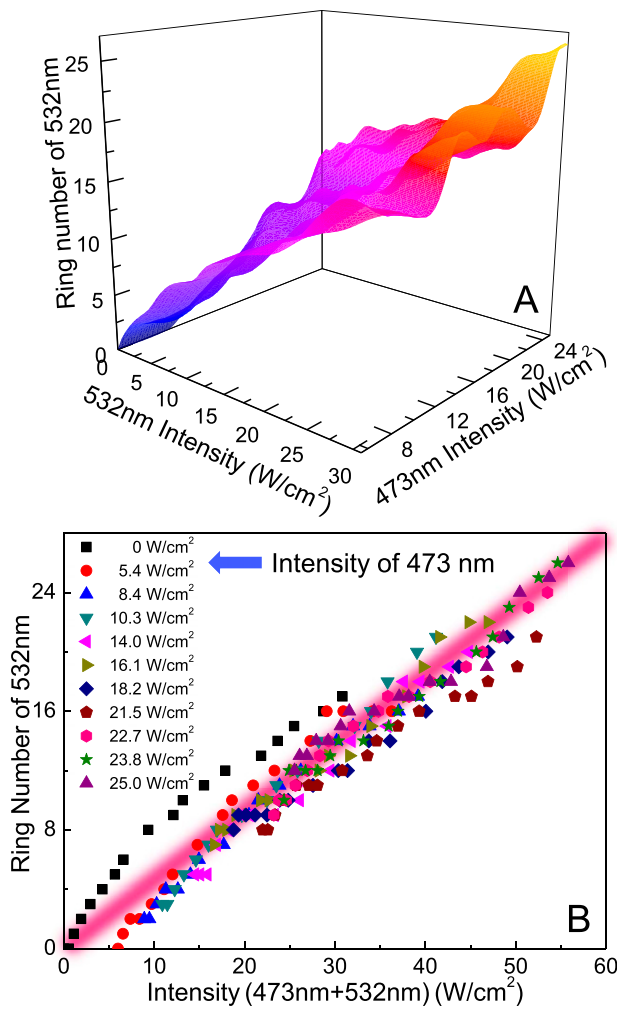


Fig. 52. Two-color all-optical switching based on SSPM. (A and B) Ring number of the 532-nm pattern, which is proportional to the sum intensity of the 532-nm and 473-nm laser beams. (A) Three-dimensional plotting of the results in B. (B) Data of multiple 473-nm laser fluences. The wide diagonal red line is a guide to the eye.

